

FORM PTO 1449 (modified) U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE LIST OF REFERENCES CITED BY APPLICANT(S) (Use several sheets if necessary)		ATTY DOCKET NO. 35.C5745 CIP/C2/D2/REI	APPLICATION NO. 09/587,249			
APPLICANT		SEISHIRO YOSHIOKA ET AL.				
FILING DATE		June 2, 2000	GROUP 1722 1722			
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EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
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KJR	5559342	9/96	Tsukamoto et al.	257	10	
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EXAMINER

KENNETH J. RAMSEY

DATE CONSIDERED

4/23/01

PRIMARY EXAMINER

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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